

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	598	(silicide salicide suicide) same (epitax\$8) same (heat\$6 anneal\$6 rta rtp (rapid adj thermal))	US-PGPUB; USPAT	OR	ON	2005/09/01 07:49
L2	41	L1 same ((etch\$6 remov\$6) with selectiv\$6)	US-PGPUB; USPAT	OR	ON	2005/09/01 07:49
L3	5733	438/300.ccls. 438/479.ccls. 438/481.ccls. 438/500.ccls. 438/502.ccls. 438/507.ccls. 438/509.ccls. 438/592.ccls. 438/607.ccls. 438/649.ccls. 438/655.ccls. 438/682.ccls. 438/683.ccls. 438/738.ccls. 438/753.ccls.	US-PGPUB; USPAT	OR	OFF	2005/09/01 08:01
L4	328	L3 and ((silicide salicide suicide) same (epitax\$8))	US-PGPUB; USPAT	OR	ON	2005/09/01 08:01
L5	320	(silicide salicide suicide) and (epitax\$8) and (heat\$6 anneal\$6 rta rtp (rapid adj thermal))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 08:26
L6	211	L5 and (etch\$6 remov\$6 selectiv\$6)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 08:26
L7	69	((silicon adj (oxide dioxide)) "sio. sub.2") same (etch\$6 with (hf hydrofluoric)) same ((dry adj etch\$6) with fluorine)	US-PGPUB; USPAT	OR	ON	2005/09/01 08:43
L8	565	438/300.ccls.	US-PGPUB; USPAT	OR	OFF	2005/09/01 08:43